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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
 10/729,194	12/05/2003	Qi Xiang	039153-5002 (G0166)	2402
34083 75	590 12/13/2005		EXAMINER	
AMD-MKE C/O FOLEY LARDNER			NGUYEN, KHIEM D	
777 EAST WISCONSIN AVENUE MILWAUKEE, WI 53202-5367			ART UNIT	PAPER NUMBER
	, ,,,		2823	
			DATE MAILED: 12/13/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
	10/729,194	XIANG, QI					
Office Action Summary	Examiner	Art Unit					
	Khiem D. Nguyen	2823					
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1) Responsive to communication(s) filed on 22 Se	entember 2005						
· <u>_</u>	action is non-final.						
·=		esecution as to the merits is					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
closed in accordance with the practice under Lx parte quayre, 1999 O.B. 11, 400 O.G. 210.							
Disposition of Claims							
4) Claim(s) 12-19 and 22-34 is/are pending in the application.							
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>12-19 and 22-34</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or	8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers							
9) The specification is objected to by the Examiner.							
10)⊠ The drawing(s) filed on <u>05 December 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a) ☐ All b) ☐ Some * c) ☐ None of:							
1. Certified copies of the priority documents	s have been received.						
2. Certified copies of the priority documents		on No.					
application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the certified copies not received.							
Attachment(s)							
1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail D	ate					
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	5)  Notice of Informal F 6)  Other:	Patent Application (PTO-152)					

# DETAILED ACTION

## Claim Rejections - 35 USC § 102

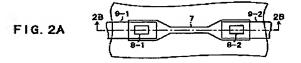
The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

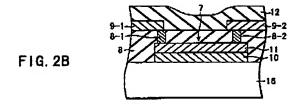
(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 12-19, 22-25, 28-30 and 33-34 are rejected under 35 U.S.C. 102(e) as being anticipated by Toyoshima (U.S. Patent 6,703,680).

In re claim 12, <u>Toyoshima</u> discloses a fuse for an integrated circuit, the fuse comprising a material 11 capable of existing in a first phase (NiSi) or a second phase (NiSi<sub>2</sub>) in response to at least one of a current signal and a voltage signal, the fuse having a different resistance in the first phase (20  $\mu\Omega$ cm) than in the second phase (60  $\mu\Omega$ cm) (col. 3, lines 15-56 and FIGS. 2A-B).



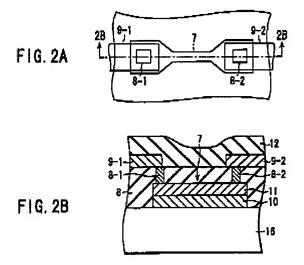
In re claim 13, <u>Toyoshima</u> discloses that the fuse further comprises a layer of material including silicon 10 and a silicide layer 11 (col. 3, lines 19-45 and FIG. 2B).



In re claim 14, <u>Toyoshima</u> discloses that the silicide 11 includes nickel (NiSi) (col. 3, lines 19-45).

In re claim 15, <u>Toyoshima</u> discloses that the first phase includes mononickel silicide (NiSi) and the second phase includes nickel disilicide (NiSi<sub>2</sub>) (col. 3, lines 35-45).

In re claim 16, <u>Toyoshima</u> discloses an integrated circuit comprising: a polysilicon layer 10 disposed above an insulative structure 16; and a silicide layer 11 disposed above the polysilicon layer 10, the silicide layer 11 being a first type (NiSi) and being convertible to a silicide layer of a second type (NiSi<sub>2</sub>) in response to a signal, wherein a resistance of the silicide layer changes when the silicide layer is converted from the first type (20  $\mu\Omega$ cm) to the second type (60  $\mu\Omega$ cm) (col. 3, lines 35-56 and FIGS. 2A-B).



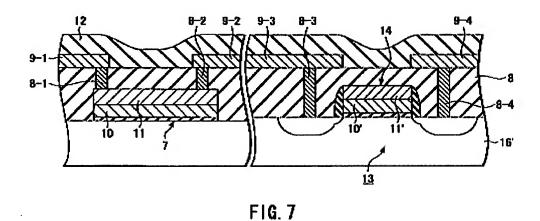
In re claim 17, <u>Toyoshima</u> discloses that the silicide layer of the first type is mononickel silicide (NiSi) (col. 3, lines 35-45).

Application/Control Number: 10/729,194

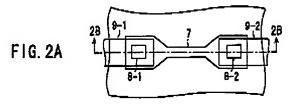
Art Unit: 2823

In re claim 18, <u>Toyoshima</u> discloses that the silicide layer of the second type is nickel disilicide (NiSi<sub>2</sub>) (col. 3, lines 35-45).

In re claim 19, <u>Toyoshima</u> discloses that the insulative structure is a field oxide or an insulative layer (FIG. 7).



In re claim 22, <u>Toyoshima</u> discloses a fuse comprises: means for having a first phase (NiSi) and a second phase (NiSi<sub>2</sub>), the first phase (20  $\mu\Omega$ cm) having a different resistivity than the second phase (60  $\mu\Omega$ cm) (col. 3, lines 35-45); and means for receiving a current and changing the means for having from the first phase to the second phase with the current (col. 3, line 46 to col. 4, line 8 and FIGS. 2A-3).



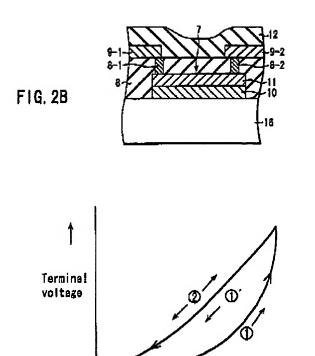


FIG. 3

In re claim 23, <u>Toyoshima</u> discloses that the second phase (60  $\mu\Omega$ cm) is a relatively higher resistance than the first phase (20  $\mu\Omega$ cm) (col. 3, lines 35-45).

Current -

In re claim 24, <u>Toyoshima</u> discloses that the current is a programming current (col. 3, line 46 to col. 4, line 8).

In re claim 25, <u>Toyoshima</u> discloses that the means for having is a material having a first sheet resistance in the second phase of at least two times of a second sheet resistance in the second phase (col. 3, lines 35-45).

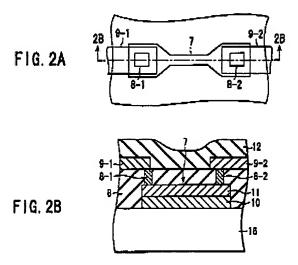
In re claim 28, <u>Toyoshima</u> discloses that the means for having is a material including nickel (NiSi) (col. 3, lines 35-45).

Art Unit: 2823

In re claim 29, <u>Toyoshima</u> discloses that the material is a silicide (NiSi) (col. 3, lines 35-45).

In re claim 30, <u>Toyoshima</u> discloses that first phase includes mononickel silicide (NiSi) and the second phase includes nickel disilicide (NiSi<sub>2</sub>) (col. 3, lines 35-45).

In re claim 33, <u>Toyoshima</u> discloses that a fuse for an integrated circuit, the fuse comprising: a silicide layer (NiSi) 11; and a layer including silicon 10, the layer including silicon being above a bulk silicon substrate 16 or a field oxide structure and below the silicide layer, wherein the silicide layer is configured in a fuse pattern, wherein the silicide layer 11 is in a first phase (NiSi), the first phase being convertible to a second phase (NiSi<sub>2</sub>), the first phase (20  $\mu\Omega$ cm) having a different resistance characteristic than the second phase (60  $\mu\Omega$ cm) (col. 3, lines 15-56 and FIGS. 2A-B).



In re claim 34, <u>Toyoshima</u> discloses that the fuse of claim 33 further comprising: conductive vias 8-1, 8-2 at a first end and a second end of the fuse pattern (col. 3, lines 19-34 and FIGS. 2A-B).

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 26-27 and 31-32 are rejected under 35 U.S.C. 103(a) as being unpatentable over Toyoshima (U.S. Patent 6,703,680).

In re claims 26-27, <u>Toyoshima</u> discloses a first sheet resistance that is several times the second sheet resistance (col. 3, lines 19-56) but does not explicitly disclose that the first sheet resistance is at least 8 times the second sheet resistance as recited in claim 26, and approximately 10 times the second sheet resistance as recited in claim 27.

However, there is no evidence indicating the ranges of the first and second sheet resistance is critical and it has been held that it is not inventive to discover the optimum or workable range of a result-effective variable within given prior art conditions by routine experimentation. See MPEP § 2144.05. Note that the specification contains no disclosure of either the critical nature of the claimed dimensions of any unexpected results arising there from. Where patentability is aid to be based upon particular chosen dimensions or upon another variable recited in a claim, the Applicant must show that the chosen dimensions are critical. <u>In re Woodruff</u>, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

Application/Control Number: 10/729,194 Page 8

Art Unit: 2823

In re claims 31-32, <u>Toyoshima</u> does not explicitly disclose that the first phase has a sheet resistance between 1-5 ohms per square and the second phase has a sheet resistance between 10 and 40 ohms per square.

However, there is no evidence indicating the ranges of the sheet resistance of the first and second phase is critical and it has been held that it is not inventive to discover the optimum or workable range of a result-effective variable within given prior art conditions by routine experimentation. See MPEP § 2144.05. Note that the specification contains no disclosure of either the critical nature of the claimed dimensions of any unexpected results arising there from. Where patentability is aid to be based upon particular chosen dimensions or upon another variable recited in a claim, the Applicant must show that the chosen dimensions are critical. In re Woodruff, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

# Response to Applicant's Amendment and Arguments

Applicant's arguments filed 09/22/2005 have been fully considered but they are not persuasive.

Applicant contends that the reference Toyoshima (U.S. Patent 6,703,680) herein known as Toyoshima, is not available as a prior art reference against the claims of the present application because a Declaration by the inventor pursuant to 37. C.F.R. § 1.131 has been provided herewith.

In response to Applicant's contention that Toyoshima, is not available as a prior art reference against the claims of the present application because a Declaration by the inventor pursuant to 37. C.F.R. § 1.131 has been provided herewith. Examiner

Application/Control Number: 10/729,194

Art Unit: 2823

respectfully submits that even though the Declaration under 37. C.F.R. § 1.131 as submitted by the Applicant shows (A) "reduction to practice of the invention..." and (B) "conception of the invention prior to the effective date of the reference..." it lacks of evidence to show or provide (C) "conception of the invention prior to the effective date of the reference coupled with due diligence from prior to the reference date to the filing date of the application (constructive reduction to practice)" (See MPEP § 715.07(a)).

Page 9

#### III. THREE WAYS TO SHOW PRIOR INVENTION

The affidavit or declaration must state FACTS and produce such documentary evidence and exhibits in support thereof as are available to show conception and completion of invention in this country or in a NAFTA or WTO member country (MPEP § 715.07(c)), at least the conception being at a date prior to the effective date of the reference. Where there has not been reduction to practice prior to the date of the reference, the applicant or patent owner must also show diligence in the completion of his or her invention from a time just prior to the date of the reference continuously up to the date of an actual reduction to practice or up to the date of fling his or her application (fling constitutes a constructive reduction to practice, 37 CFR 1.131).

As discussed above, 37 CFR 1.131(b) provides three ways in which an applicant can establish prior invention of the claimed subject matter. The showing of facts must be sufficient to show.

- (A) > (actual)< reduction to practice of the invention prior to the effective date of the reference; or
- (B) conception of the invention prior to the effective date of the reference coupled with due diligence from prior to the reference date to a subsequent (actual) reduction to practice; or
- (C) conception of the invention prior to the effective date of the reference coupled with due diligence from prior to the reference date to the filing date of the application (constructive reduction to practice).

### 715.07(a) Diligence

Where conception occurs prior to the date of the reference, but reduction to practice is afterward, it is not enough merely to allege that applicant or patent owner had been diligent. Ex parte Hunter, 1889 C.D. 218, 49 O.G. 733 (Comm'r Pat. 1889). Rather, applicant must show evidence of facts establishing diligence.

In determining the sufficiency of a 37 CFR 1.131 affidavit or declaration, diligence need not be considered unless conception of the invention prior to the effective date is clearly established, since diligence comes into question only after prior conception is established. Ex parte Kantor, 177 USPQ 455 (Bd. App. 1958).

What is meant by diligence is brought out in Christie v. Seybold, 1893 C.D. 515, 64 O.G. 1650 (6th Cir. 1893). In patent law, an inventor is either diligent at a given time or he is not diligent; there are no degrees of diligence. An applicant may be diligent within the meaning of the patent law when he or she is doing nothing, if his or her lack of activity is excused. Note, however, that the record must set forth an explanation or excuse for the inactivity, the USPTO or courts will not speculate on possible explanations for delay or inactivity. See In re Nelson, 420 F.2d 1079, 164 USPO 458 (CCPA 1970). Diligence must be judged on the basis of the particular facts in each case. See MPEP § 2138.06 for a detailed discussion of the diligence requirement for proving prior invention. Under 37 CFR 1.131, the critical period in which diligence must be shown begins just prior to the effective date of the reference or activity and ends with the date of a reduction to practice, either actual or constructive (i.e., filing a United States patent application). Note, therefore, that only diligence before reduction to practice is a material consideration. The 'lapse of time between the completion or reduction to practice of an invention and the filing of an application thereon" is not relevant to an affidavit or declaration under 37 CFR 1,131. See Ex parte Merz, 75 USPQ 296 (Bd. App. 1947). Form paragraph 7.62 (reproduced in MPEP § 715) may be used to respond to a 37 CFR 1.131 affidavit where diligence is lacking.

For these reasons, examiner holds the rejection proper.

#### Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any

Application/Control Number: 10/729,194 Page 11

Art Unit: 2823

extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Khiem D. Nguyen whose telephone number is (571) 272-1865. The examiner can normally be reached on Monday-Friday (8:30 AM - 5:30 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew S. Smith can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

K.N. December 5, 2005

> W. DAVID COLEMAN BRIMARY EXAMINER